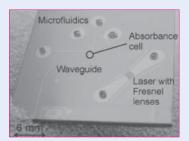
micro resist technology GmbH Koepenicker Straße 325 12555 Berlin-Koepenick Germany Telephone +49 30 65762192 Fax +49 30 65762193 E-Mail mrt@microresist.de www.microresist.com

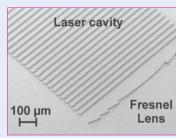


## **Thermoplastic Polymer for Imprinting**

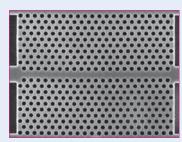
#### mr-I T85 – New Polymer for lab-on-a-chip, optical and bio applications



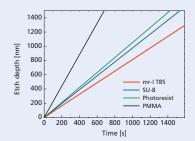
Complete lab-on-a-chip device for absorption measurements, all components imprinted in one layer of mr-I T85 (courtesy of MIC / TU Denmark)



Microfluidic dye laser and Fresnel lens imprinted in mr-I T85 (courtesy of MIC / TU Denmark)



Photonic wave guide filter fabricated using mr-I T85, 320 nm deep holes transferred into silicon (200 nm diameter) (courtesy of MIC / TU Denmark)



Etch depth as a function of time,  $SF_6/O_2$  plasma

The new mr-I T85 series has been developed preferably for permanent applications in lab-on-a-chip systems, microfluidics, and microoptical components.

#### **Unique features**

- <sup>–</sup> Unpolar thermoplastic
- <sup>–</sup> Excellent film quality
- Beneficial flow behaviour during imprinting, low imprint pressure
- <sup>–</sup> Excellent UV and optical transparency
- <sup>-</sup> High plasma etch resistance
  - <sup>-</sup> comparable to novolak-based photoresists
  - <sup>-</sup> selectivity to silicon 9:1 (Si / mr-I T85)
- High chemical stability
  - <sup>-</sup> high resistance to acids, bases and polar solvents
  - <sup>-</sup> no interactions with conventional photoresists

#### **Technical Data**

Glass transition temperature	85 °C
Imprinting conditions	130 – 150 °C
Low pressure	5 – 20 bar

Ready-to-use solutions for various film thicknesses

Туре	Thickness <sup>1)</sup>
mr-I T85-0.3	300 nm
mr-I T85-1.0	1.0 µm
mr-I T85-5.0	5.0 µm

<sup>1)</sup> 3000 rpm, 30 s

# Feature sizes can be imprinted ranging from sub-100 nm to 100 $\mu$ m. micro resist technology provides ready-to-use solutions for film thicknesses from 100 nm to 20 $\mu$ m.

### Applications

- <sup>–</sup> Lab-on-a-chip systems
- Bio applications
- Microfluidics
- <sup>-</sup> Microoptical elements
- <sup>–</sup> Wave guides
- <sup>-</sup> Single and multilayer systems
- <sup>–</sup> Mask for pattern transfer processes

#### **Process Flow**

